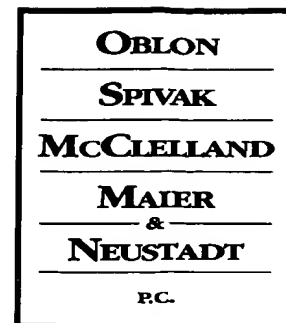




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Docket No.: 209236US0

ASSISTANT COMMISSIONER FOR PATENTS
WASHINGTON, D.C. 20231



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RE: Application Serial No.: 09/867,541
Applicants: Toshihiro OGAWA, et al.
Filing Date: May 31, 2001
For: COMPOSITION FOR POLISHING PAD AND
POLISHING PAD USING THE SAME
Group Art Unit: 1711
Examiner: U. Rajguru

SIR:

Attached hereto for filing are the following papers:

**SUPPLEMENTAL AMENDMENT W/MARKED-UP COPY; LITERATURE ARTICLE:
FAYOLLE et al.: EVALUATION OF A NEW SLURRY-FREE CMP TECHNIQUE FOR
OXIDE PLANARIZATION**

Our check in the amount of \$0.00 is attached covering any required fees. In the event any variance exists between the amount enclosed and the Patent Office charges for filing the above-noted documents, including any fees required under 37 C.F.R. 1.136 for any necessary Extension of Time to make the filing of the attached documents timely, please charge or credit the difference to our Deposit Account No. 15-0030. Further, if these papers are not considered timely filed, then a petition is hereby made under 37 C.F.R. 1.136 for the necessary extension of time. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND,
MAIER & NEUSTADT, P.C.


Norman F. Oblon

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209236US-0



IN THE UNITED STATES PATENT & TRADEMARK OFFICE

RE APPLICATION OF

Toshihiro OGAWA ET AL

SERIAL NO: 09/867,541

FILED: MAY 31, 2001

FOR: COMPOSITION FOR POLISHING :
PAD AND POLISHING PAD
USING THE SAME

:

: EXAMINER: RAJGURU, U.

:

: GROUP ART UNIT: 1711

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SUPPLEMENTAL AMENDMENT

ASSISTANT COMMISSIONER FOR PATENTS
WASHINGTON, D.C. 20231

SIR:

#5

Supplemental to the amendment filed September 9, 2002, Applicants respectfully
request reconsideration of the above-identified application in view of the following
amendment and remarks.

IN THE SPECIFICATION

Please replace Table 1 at page 28 with the following:

B1

	Example		Comparative example	
	1	2	1	2
Removal rate (nm/min.)	190	250	60	10
State of a pore	○	○	×	×
Breaking elongation (%)	100	100	>600	>600
Breaking remaining elongation (%)	0	0	510	220